**AMENDMENTS TO THE SPECIFICATION:** 

Please amend the specification as follows:

Amend the paragraph [0024] on page 4, to read as follows:

[0024] The present invention further provides in yet another aspect thereof a method of making

quantum size effect micro particles, characterized in that it comprises the steps of: introducing

silane into a VHF-band plasma of argon while controlling the time duration in which the silane is

so introduced to form Si single crystal micro particles with their particle size controlled; forming

on a substrate a layers of such Si single crystal micro particles so formed; and converting

respective surface areas of the said Si single crystal macro micro particles in the said layer on the

said substrate in the presence of a gaseous atmosphere into insulating films.

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